



Electron Transport Simulations of 4-Terminal Crossed Graphene Nanoribbons Devices

Pedro Brandimarte¹, Nick R. Papior², Mads Engelund¹,
Aran Garcia-Lekue^{3,4}, Thomas Frederiksen^{3,4}, Daniel Sánchez-Portal^{1,3}

1 Centro de Física de Materiales CSIC-UPV/EHU, Spain

2 Danmarks Tekniske Universitet Nanotech, Denmark

3 Donostia International Physics Center, Spain

4 IKERBASQUE, Basque Foundation for Science, Spain

March 14, 2016

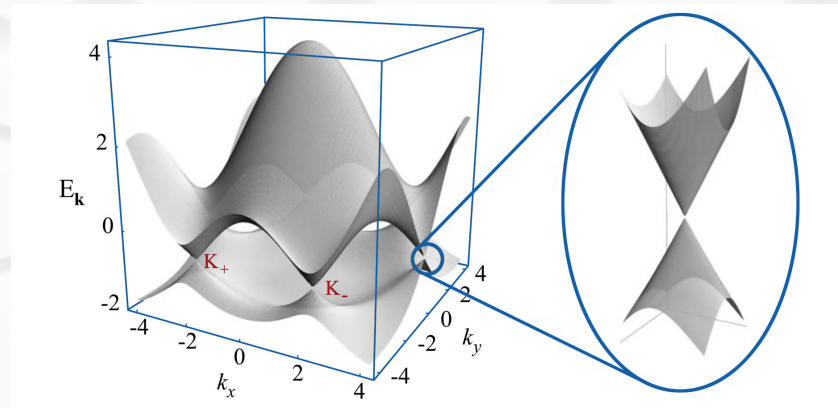


Graphene

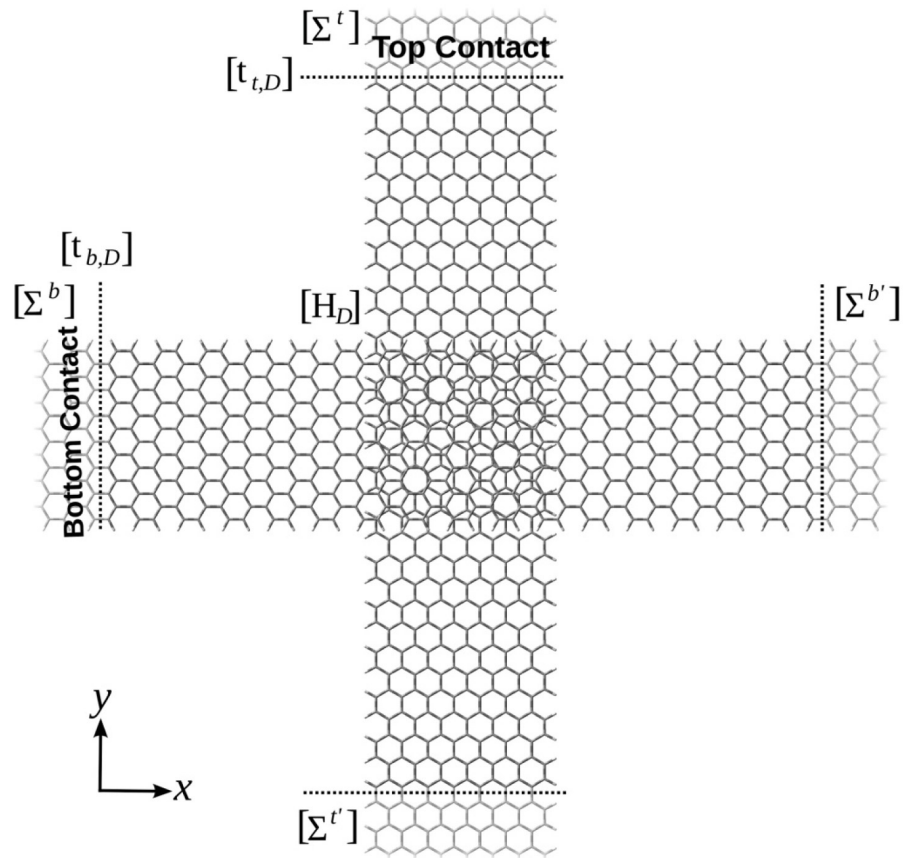
- High mobility $\longrightarrow 10^5 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$

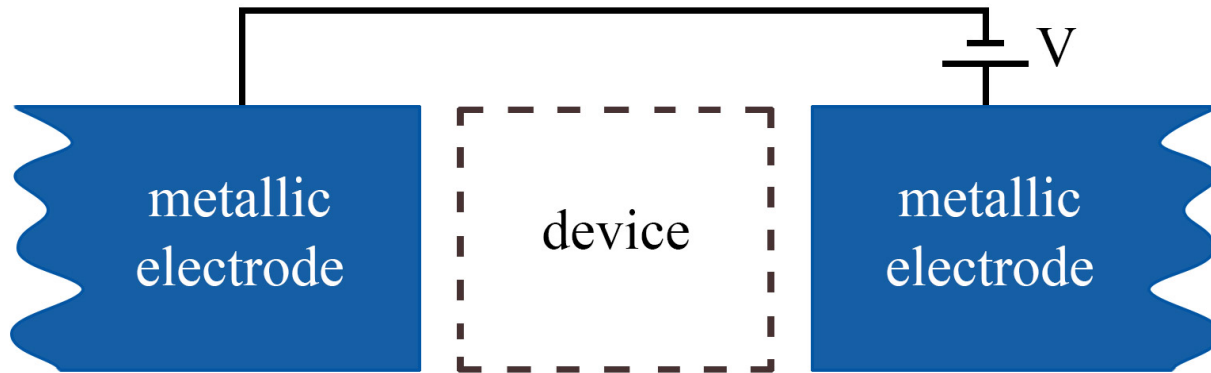
K. Novoselov *et al.* *Science* **306**, 666-669 (2004).

- Gap absence:



A. Castro Neto *et al.* *Rev. of Mod. Phys.* **81**, 109-162 (2009).





Density-Functional Theory (DFT) **SIESTA**

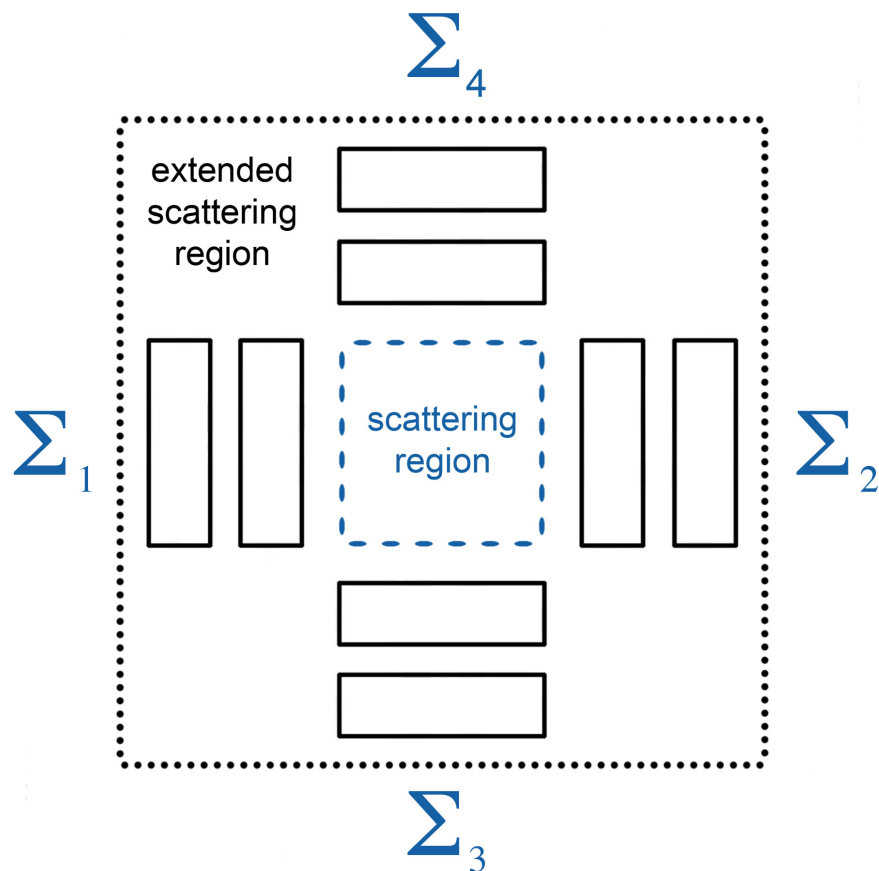
+

Non-Equilibrium Green's Function Formalism (NEGF)

TranSIESTA



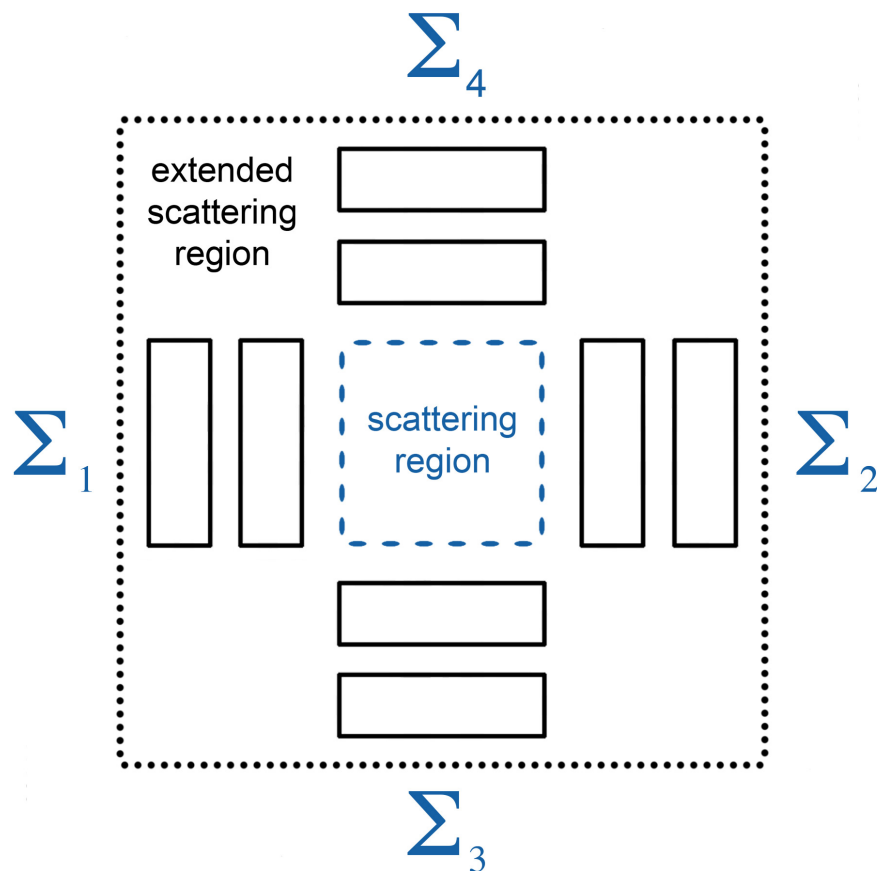
Multi-terminal TranSIESTA



$N \geq 1$ arbitrarily distributed
electrodes at finite bias



Multi-terminal TranSIESTA

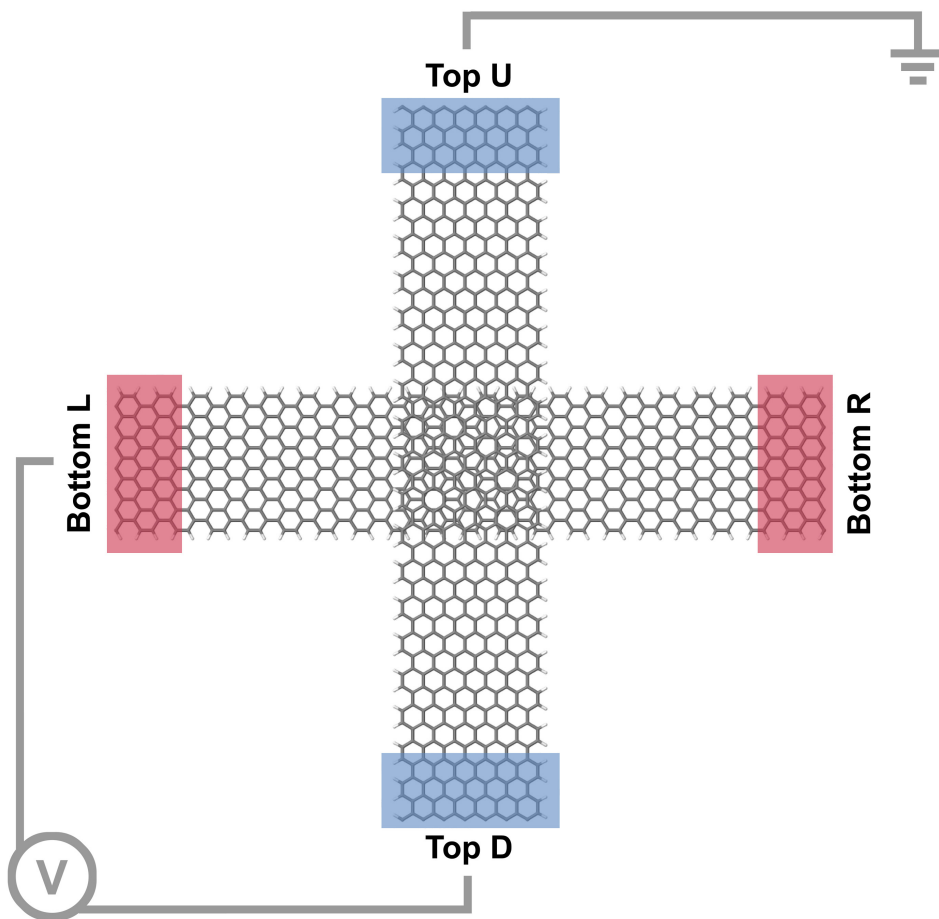


$N \geq 1$ arbitrarily distributed
electrodes at finite bias

$$V_H(\mathbf{r}) = \tilde{\phi}(\mathbf{r}) + \begin{cases} \mu_j, & \text{for } \mathbf{r} \in \mathbf{r}_j \\ 0, & \text{for } \mathbf{r} \notin \mathbf{r}_j \end{cases}$$

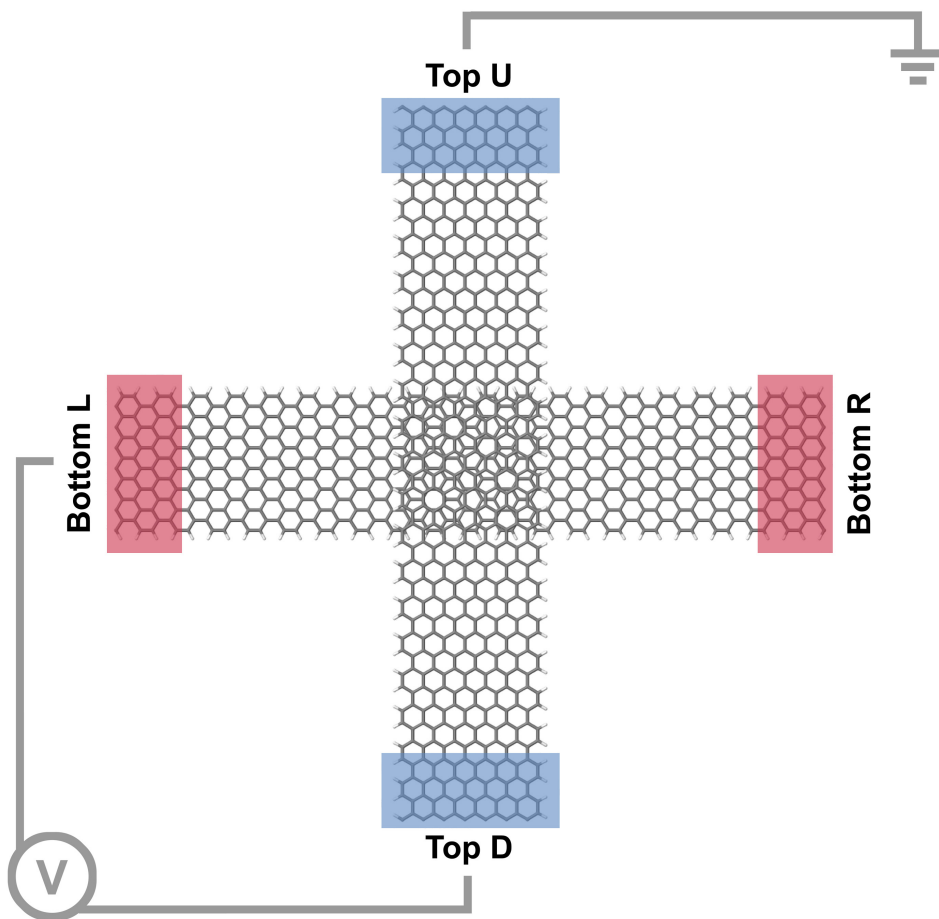


Crossed 14-AGNR





Crossed 14-AGNR



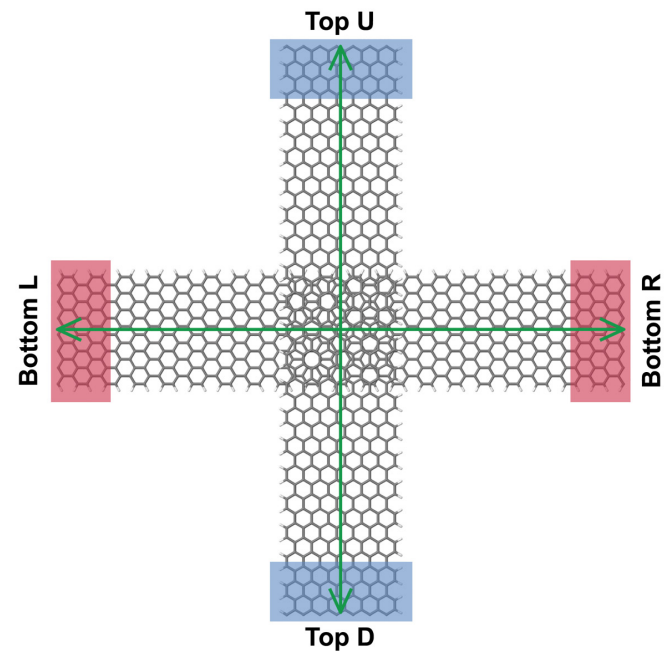
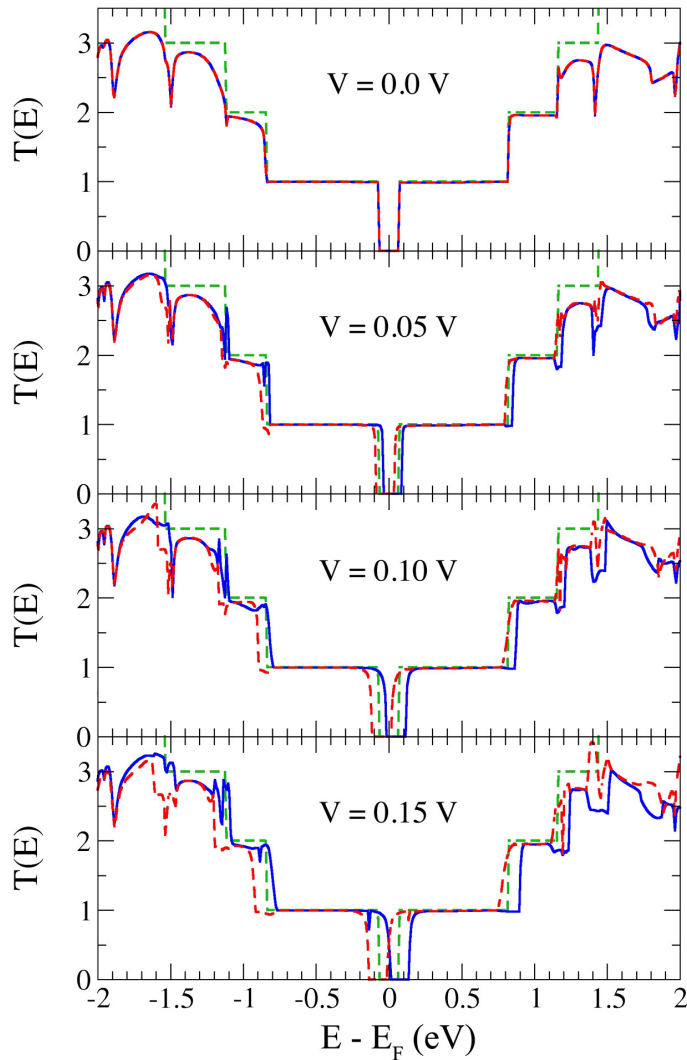
Simulation characteristics:

- 1280 atoms;
- double- ζ (9280 orbitals);
- vdW (optB88);
- real space grid cutoff: 350 Ry;
- forces < 5 meV/Å;
- interlayer distance: 3.34 Å.



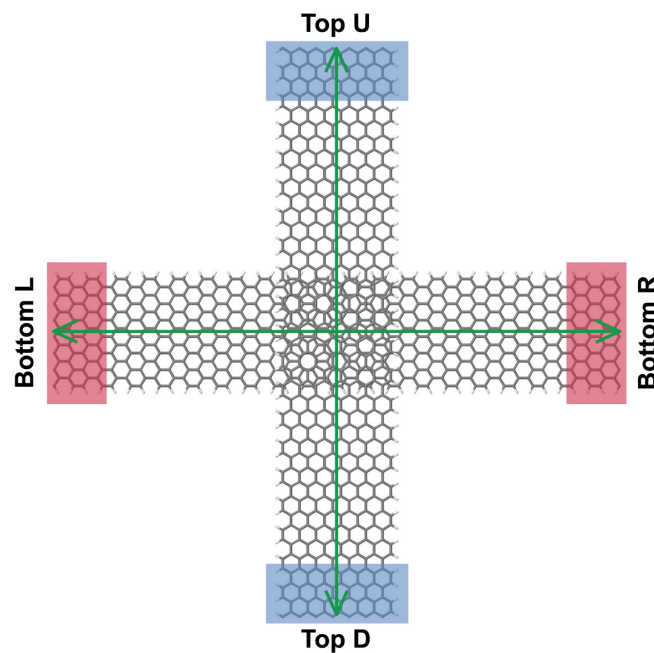
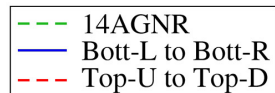
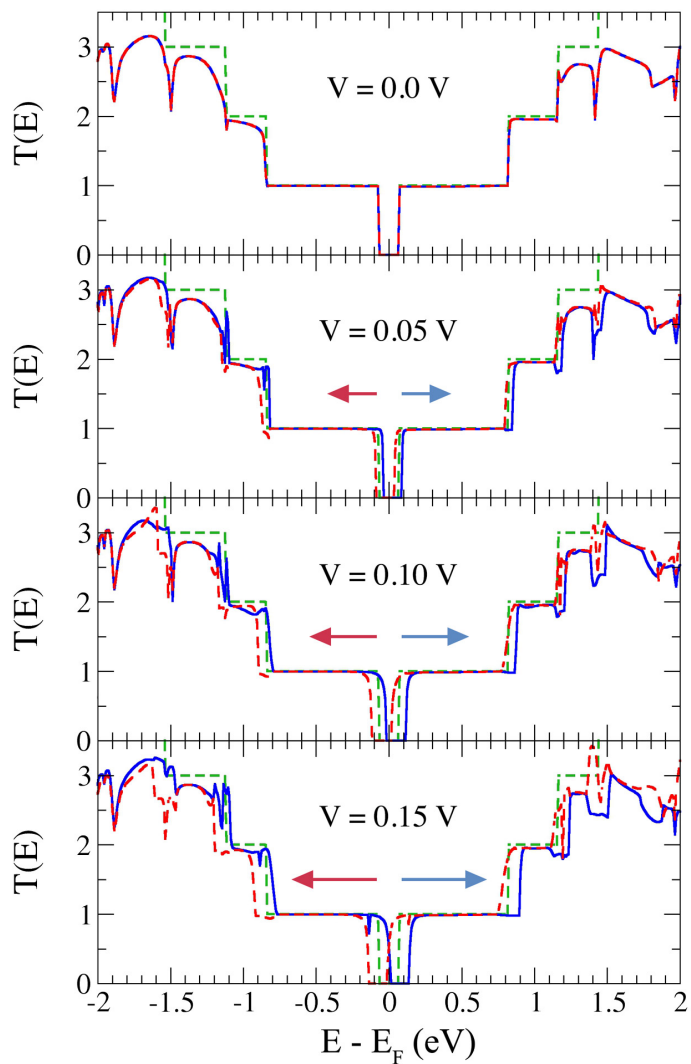


Direct transmission



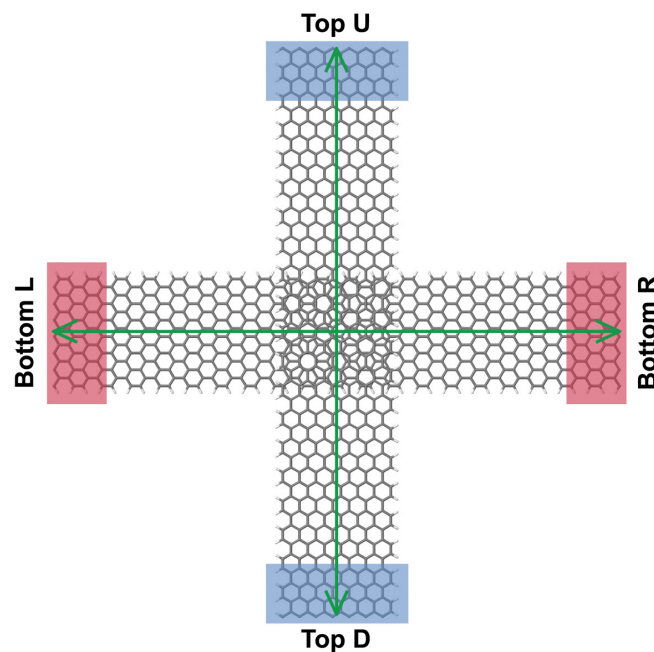
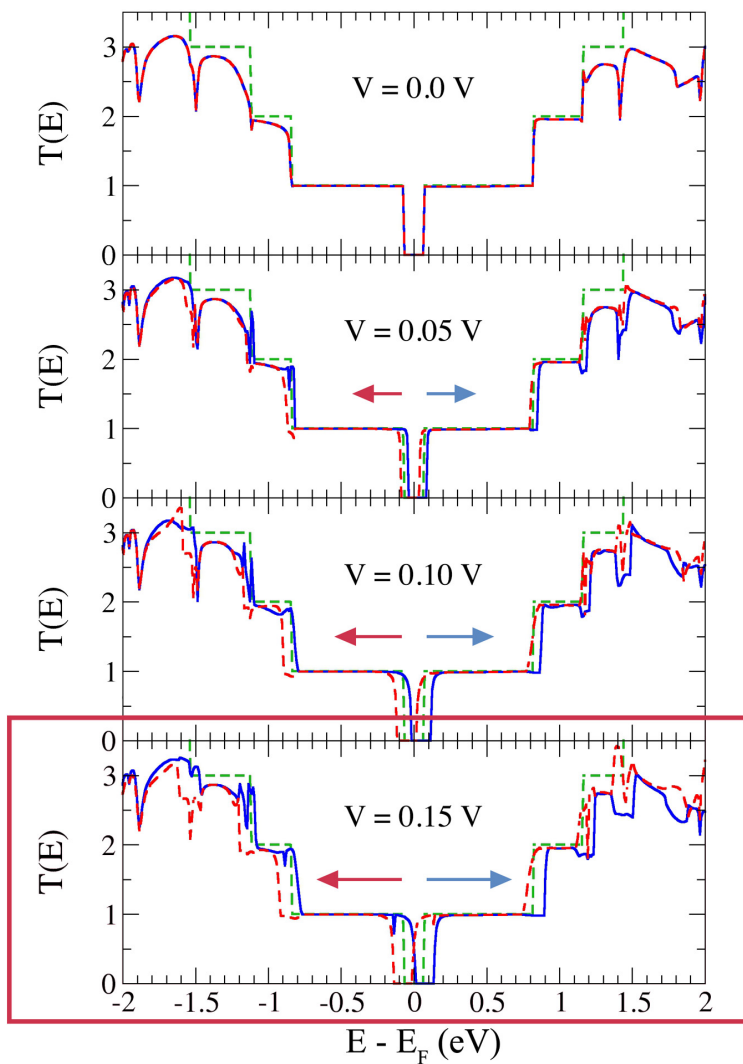


Direct transmission



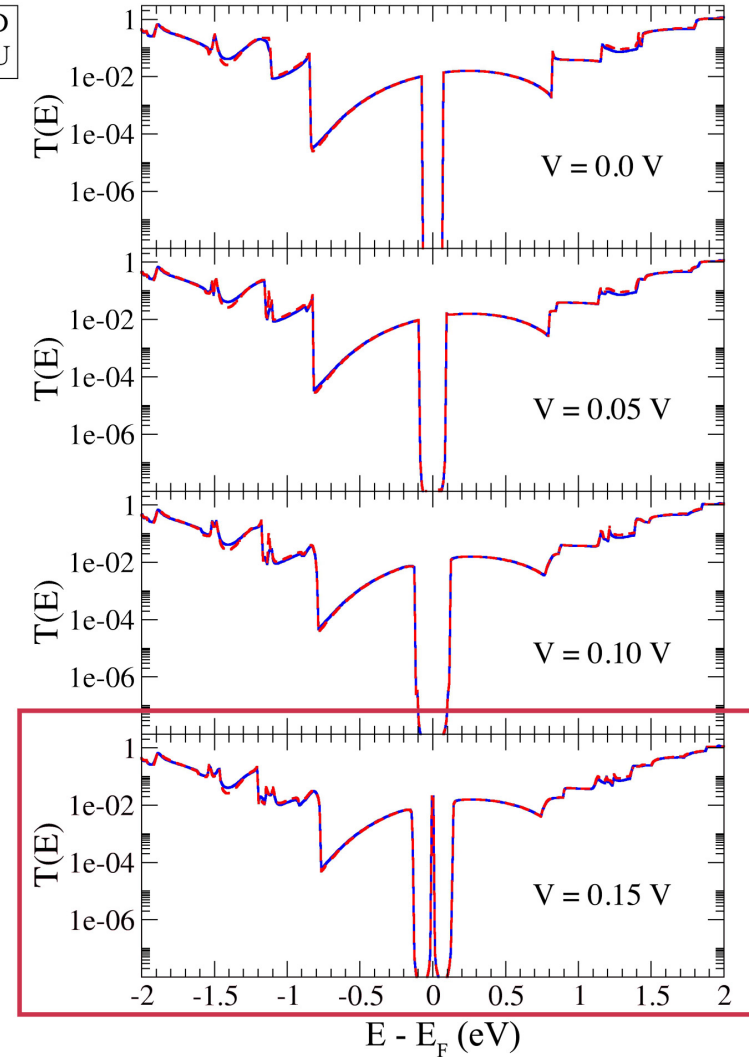
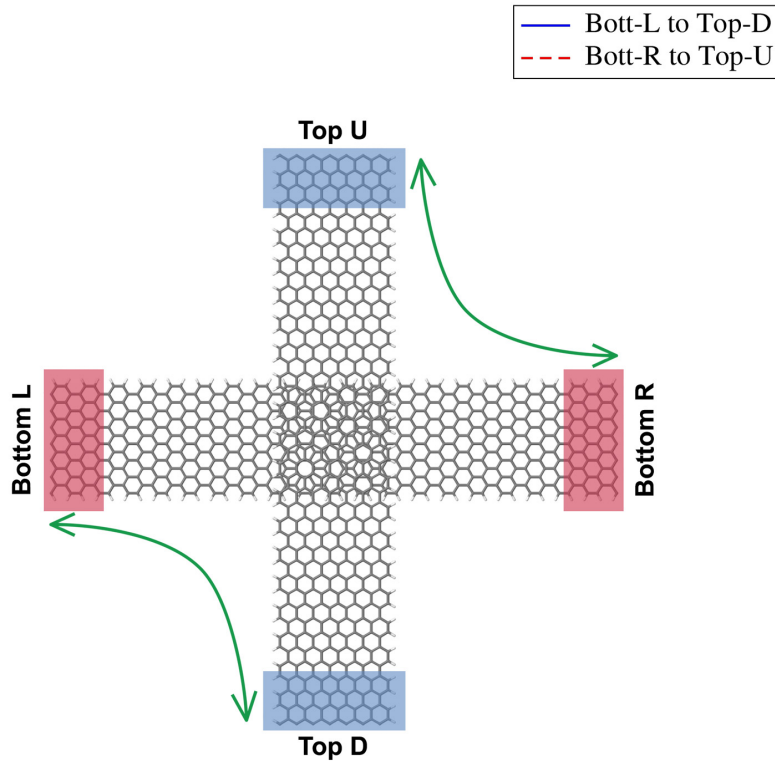


Direct transmission



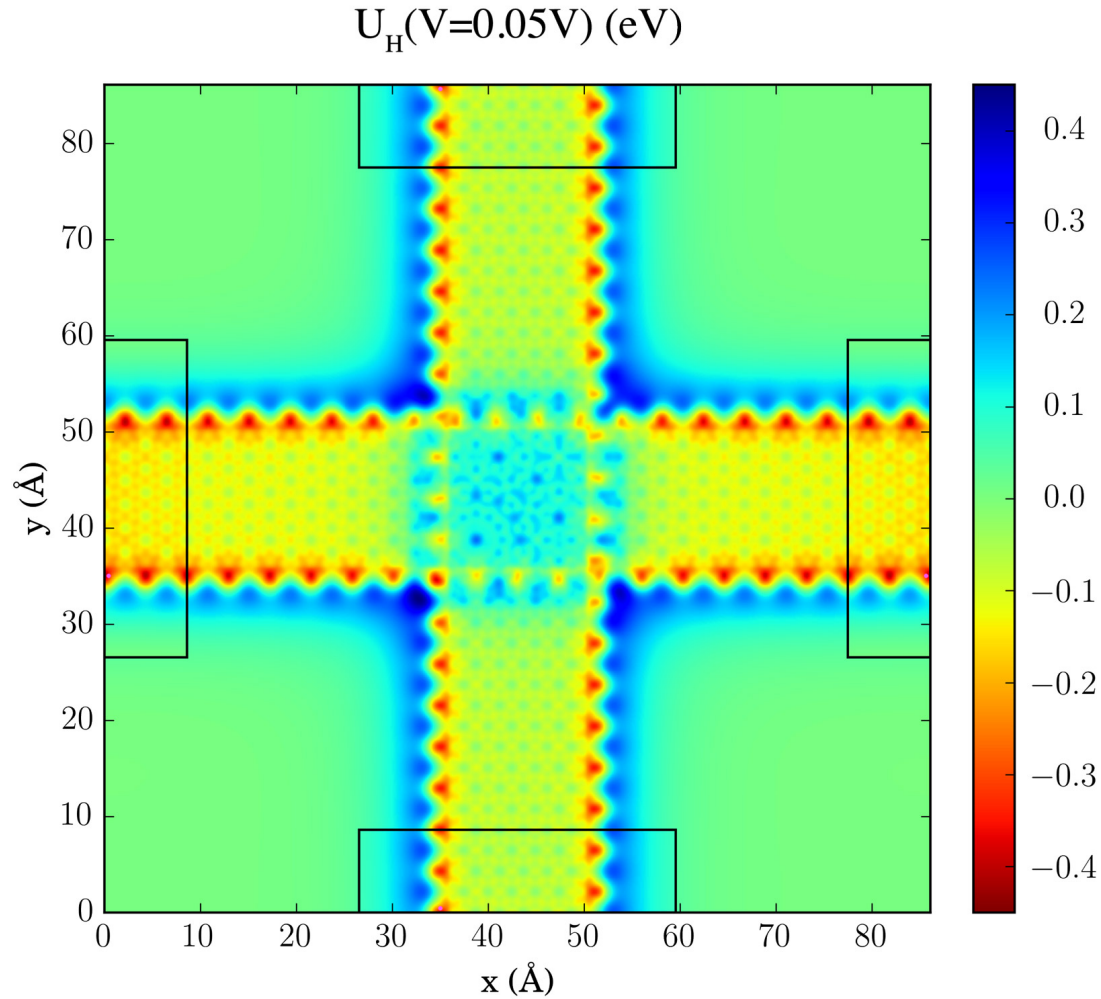


Inter-ribbon transmission





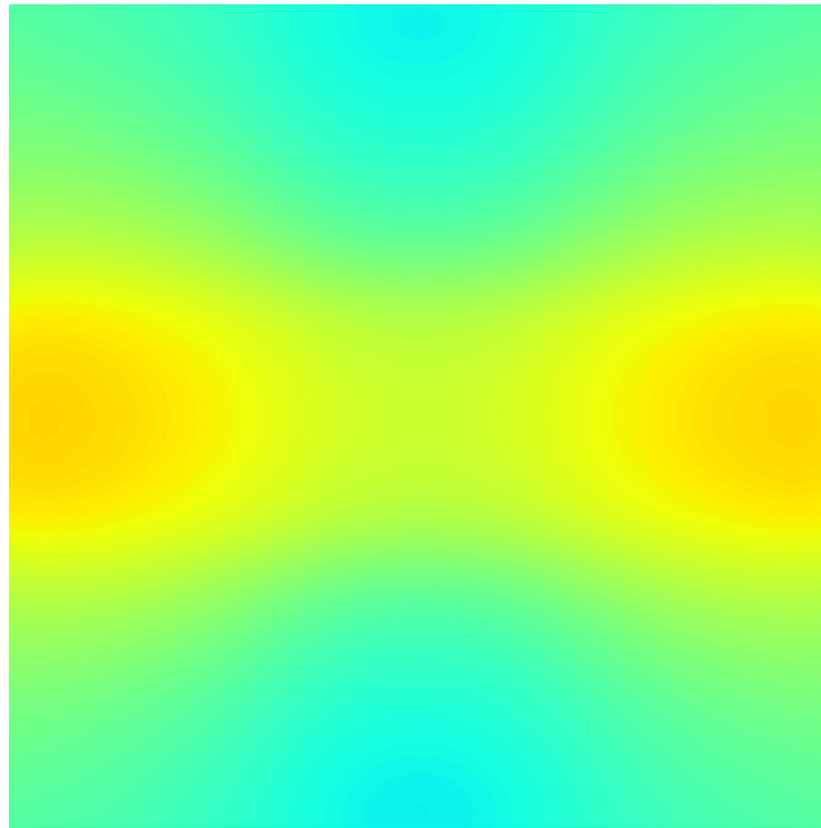
Electrostatic potential at $V = 0.05$ V





Electrostatic potential at $V = 0.05$ V

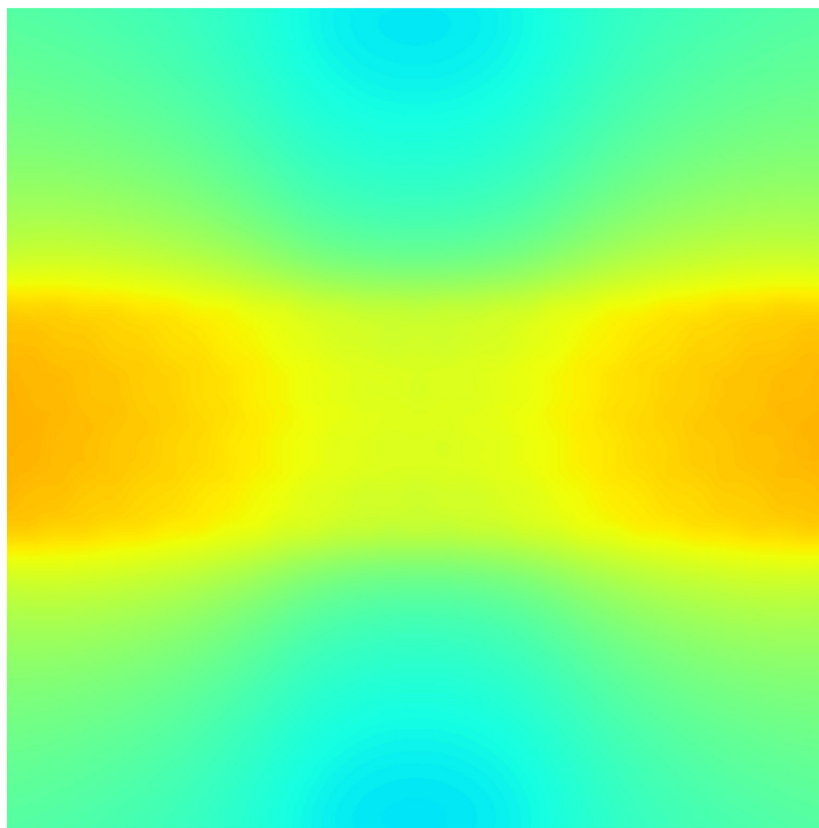
$$U_H(V=0.05V) - U_H(V=0.0V) \text{ (eV)}$$





Electrostatic potential at $V = 0.05$ V

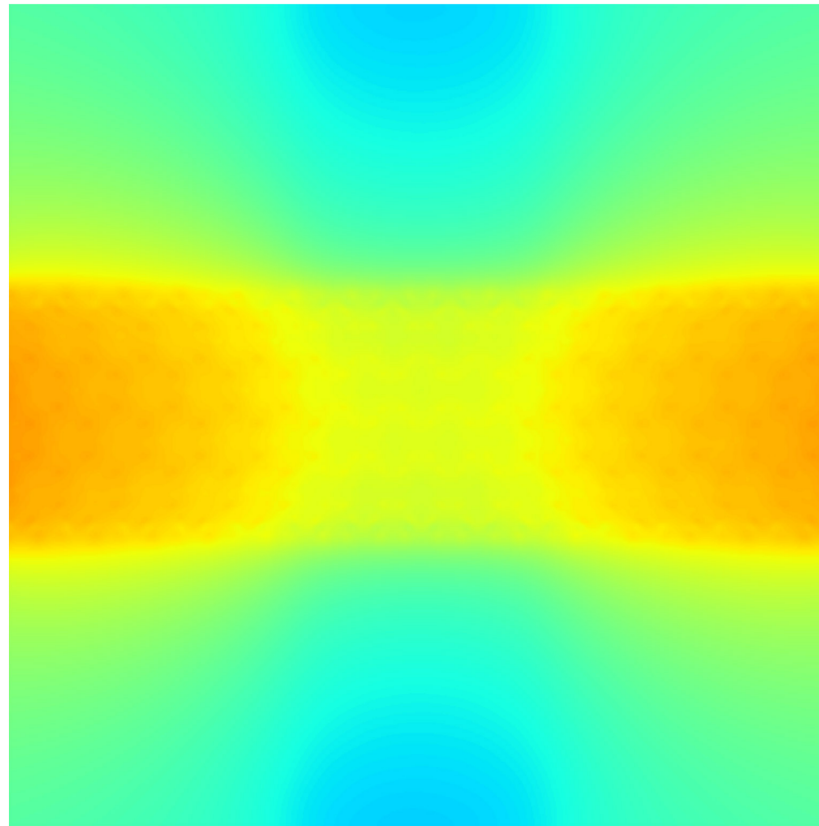
$$U_H(V=0.05V) - U_H(V=0.0V) \text{ (eV)}$$





Electrostatic potential at $V = 0.05$ V

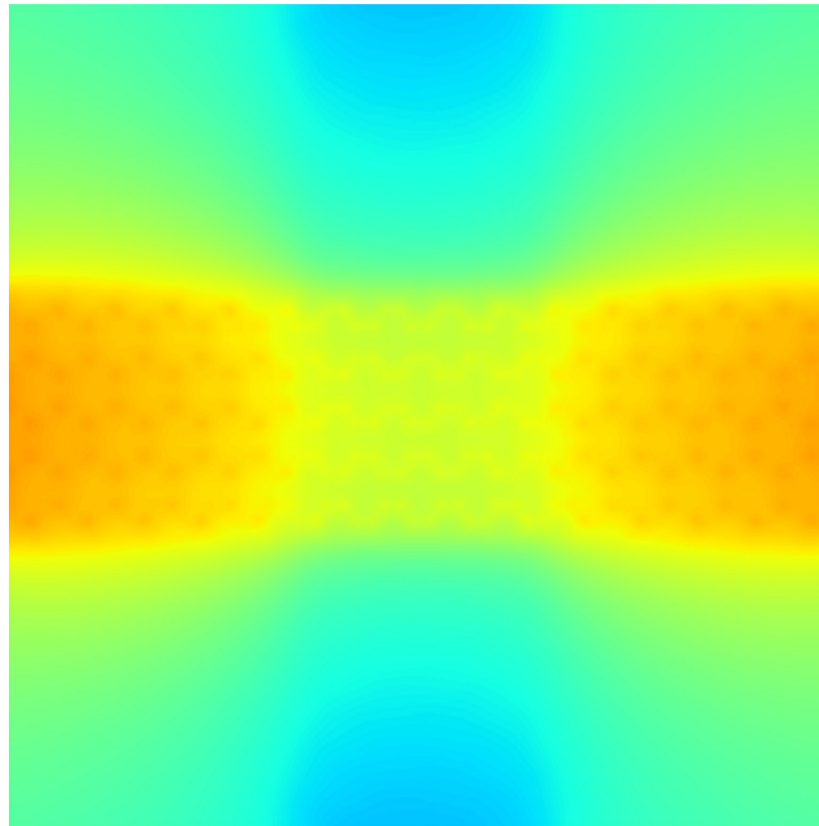
$$U_H(V=0.05V) - U_H(V=0.0V) \text{ (eV)}$$





Electrostatic potential at $V = 0.05$ V

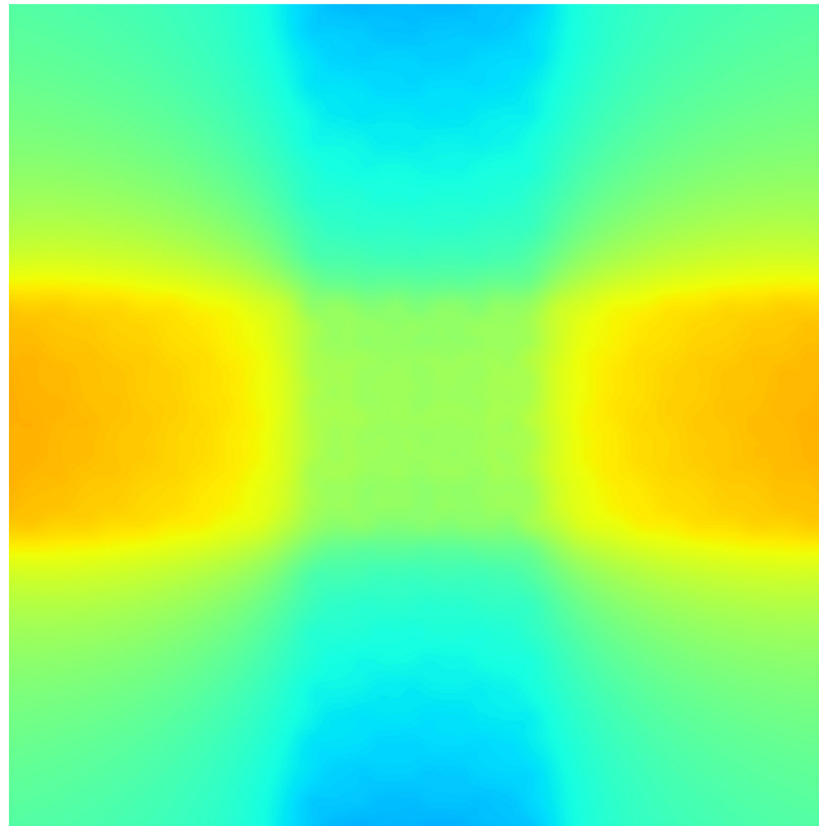
$$U_H(V=0.05V) - U_H(V=0.0V) \text{ (eV)}$$





Electrostatic potential at $V = 0.05$ V

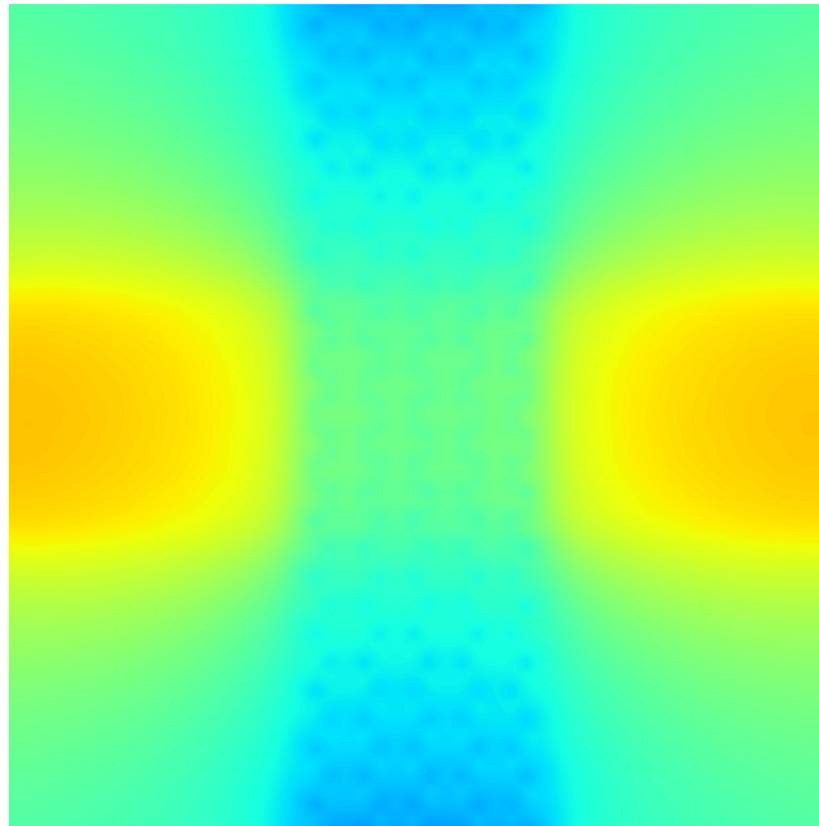
$$U_H(V=0.05V) - U_H(V=0.0V) \text{ (eV)}$$





Electrostatic potential at $V = 0.05$ V

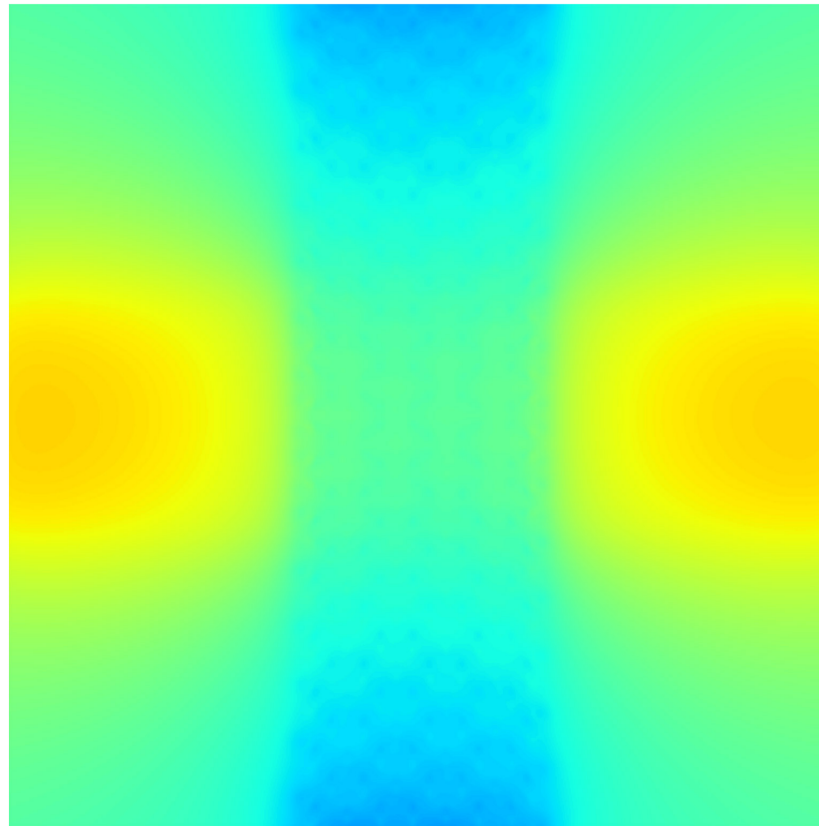
$$U_H(V=0.05V) - U_H(V=0.0V) \text{ (eV)}$$





Electrostatic potential at $V = 0.05$ V

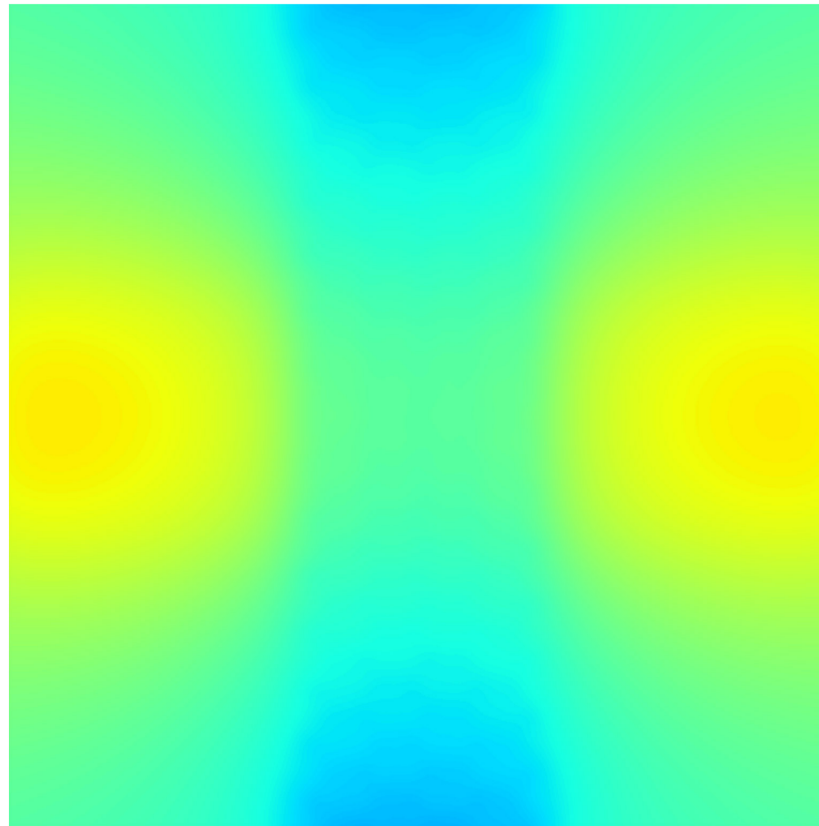
$$U_H(V=0.05V) - U_H(V=0.0V) \text{ (eV)}$$





Electrostatic potential at $V = 0.05$ V

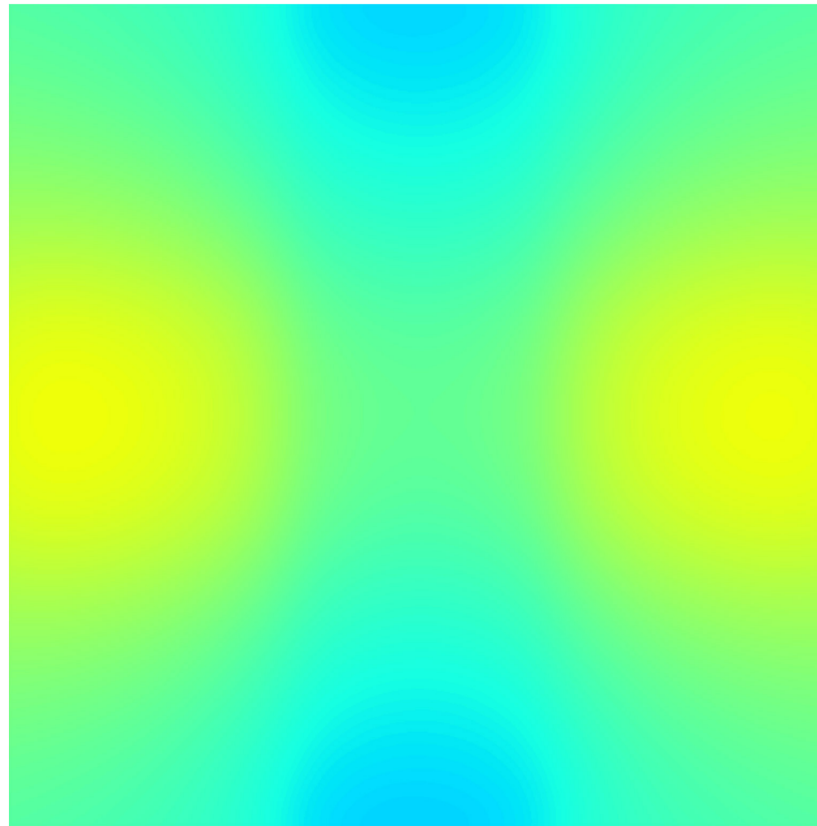
$$U_H(V=0.05V) - U_H(V=0.0V) \text{ (eV)}$$





Electrostatic potential at $V = 0.05$ V

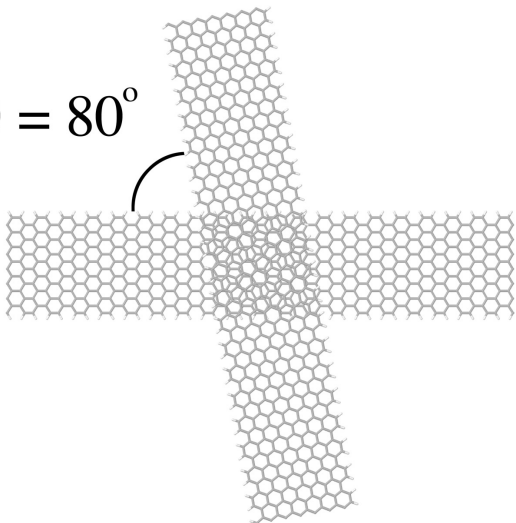
$$U_H(V=0.05V) - U_H(V=0.0V) \text{ (eV)}$$



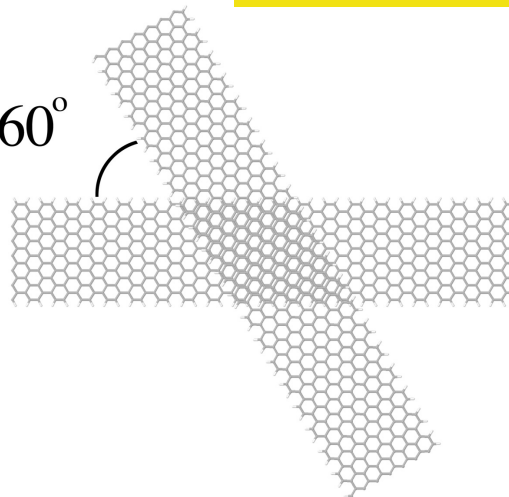


Rotated crossbar

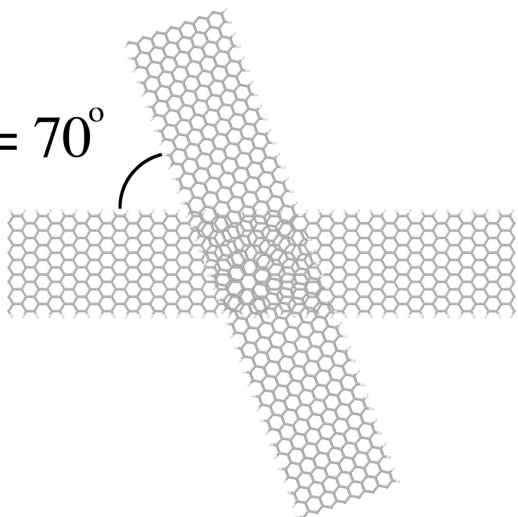
$$\theta = 80^\circ$$



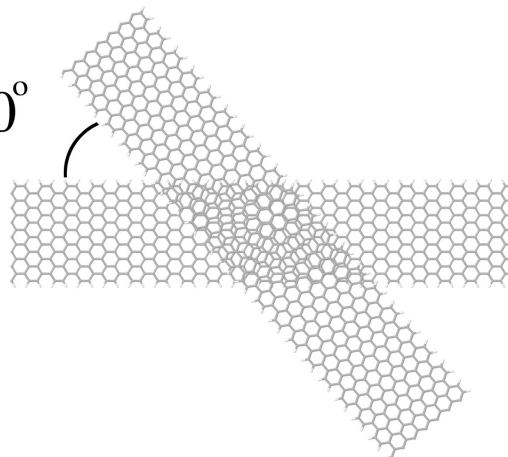
$$\theta = 60^\circ$$



$$\theta = 70^\circ$$

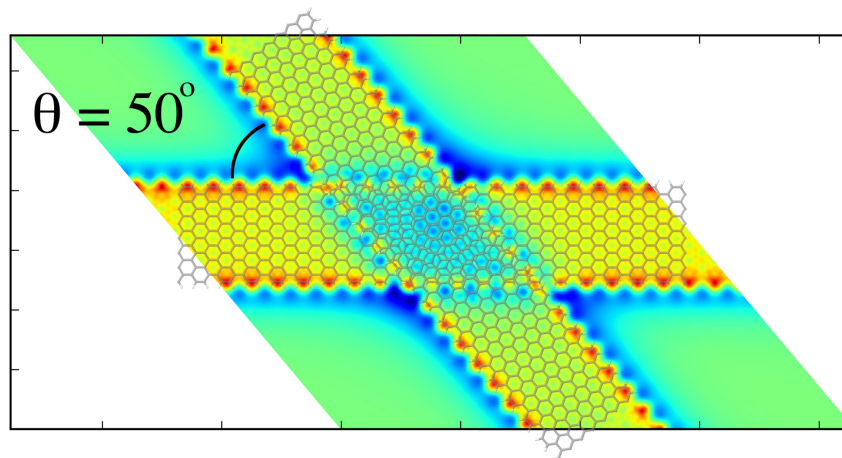
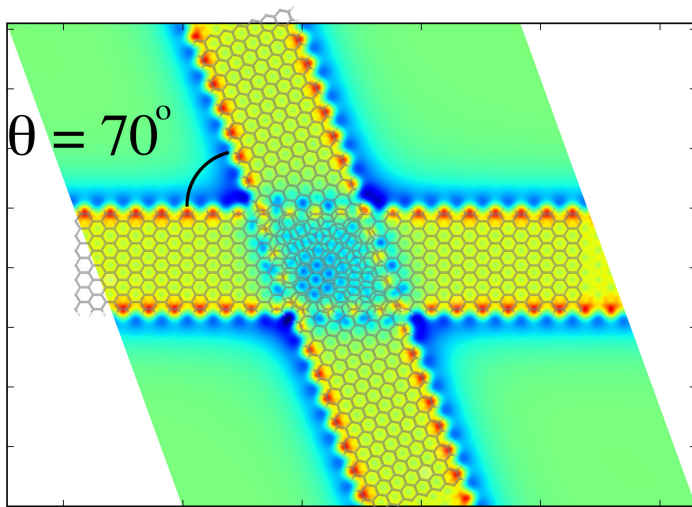
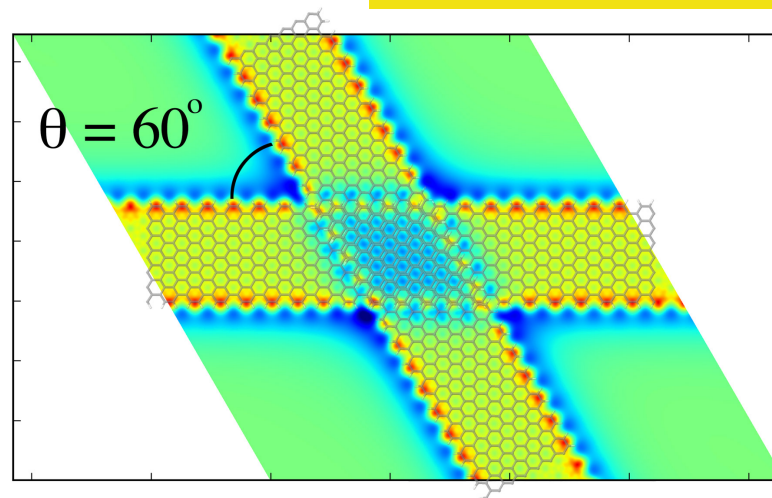
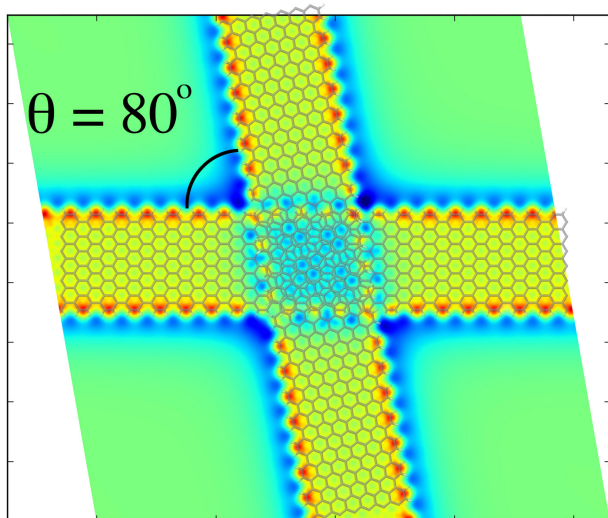


$$\theta = 50^\circ$$



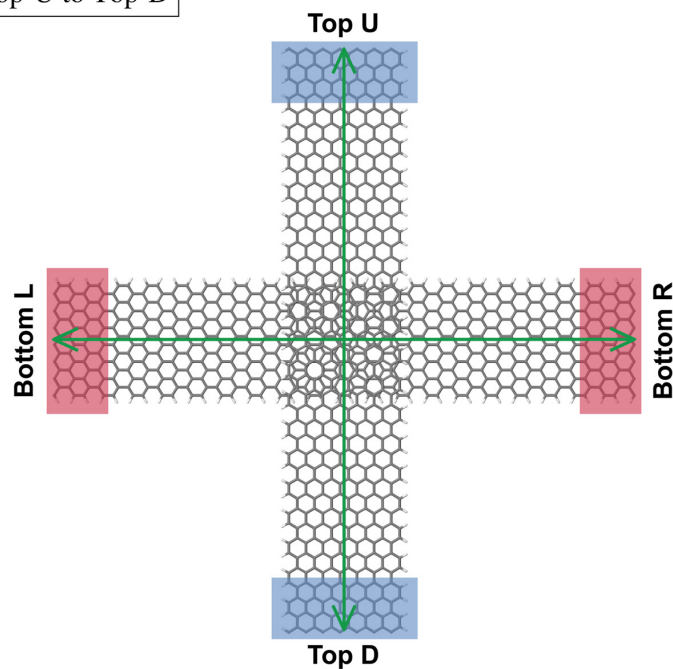
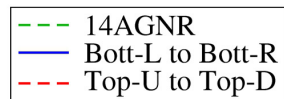
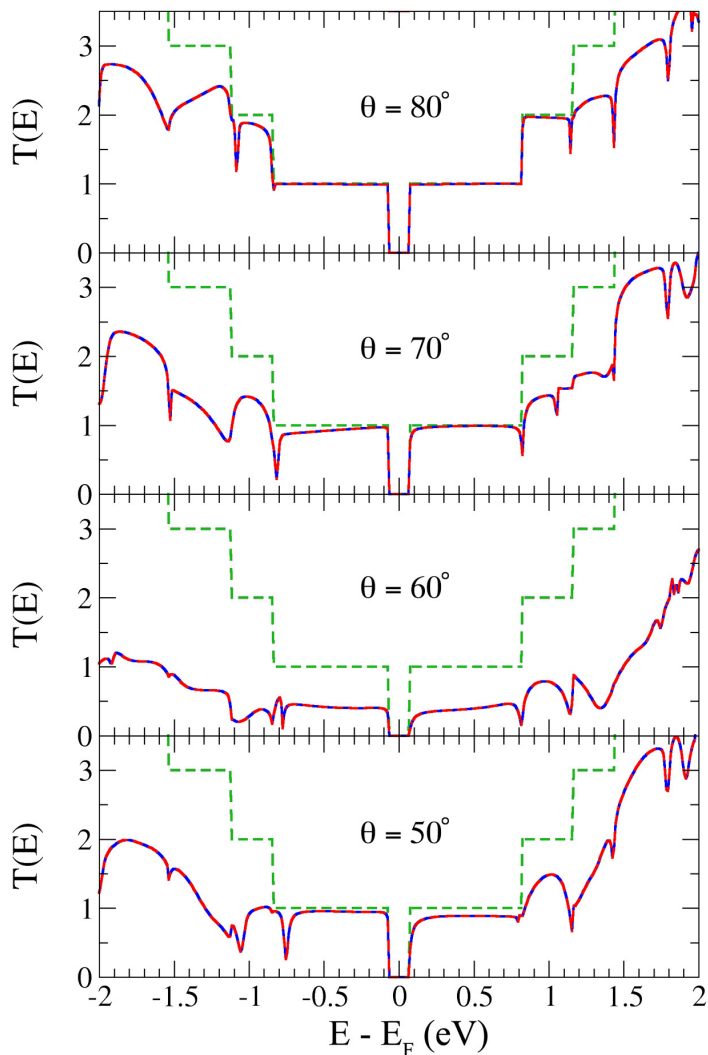


Electrostatic potential at $V = 0$



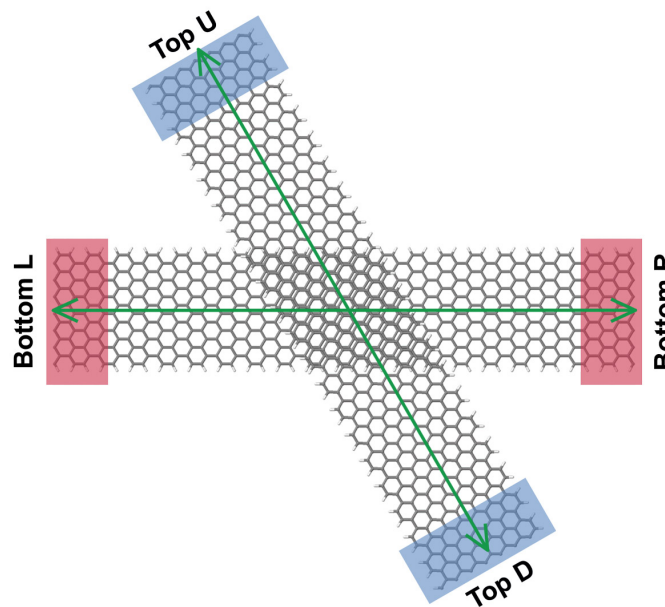
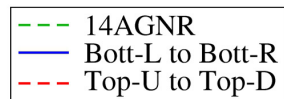
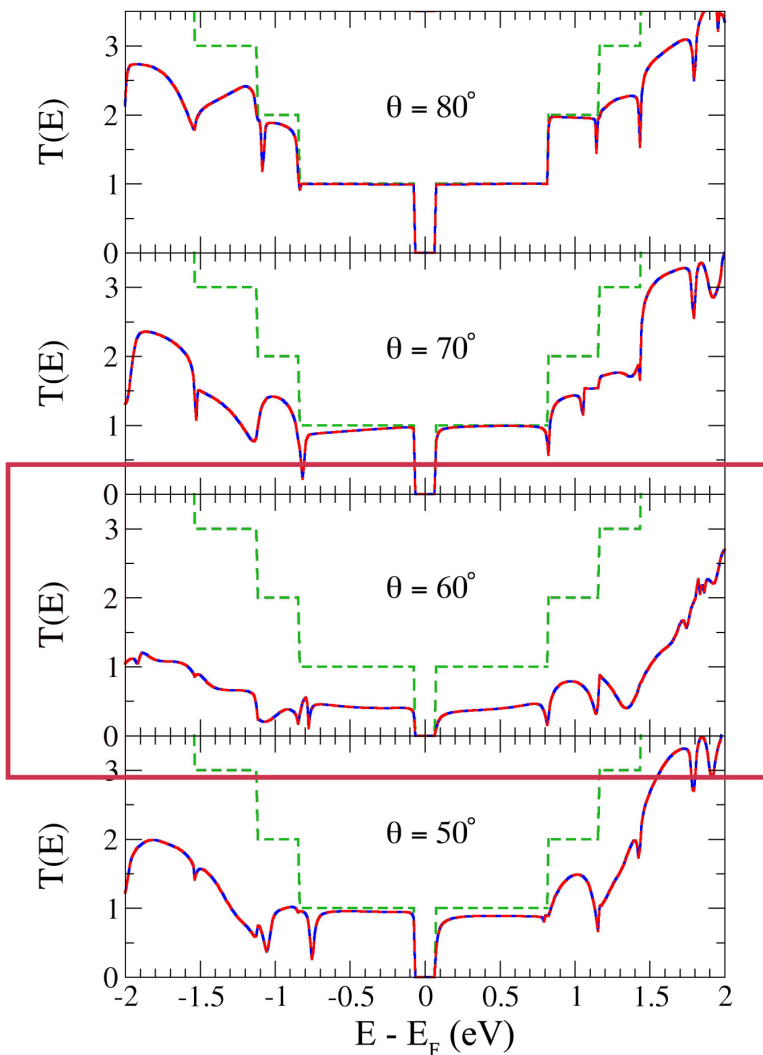


Direct transmission at $V = 0$



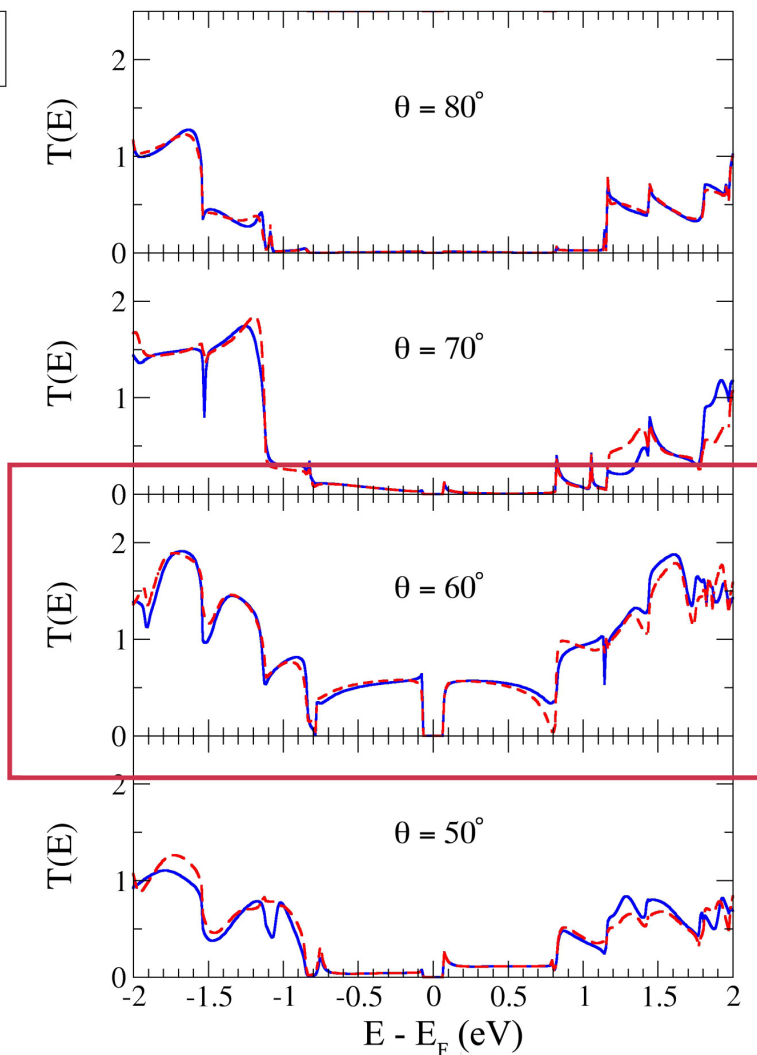
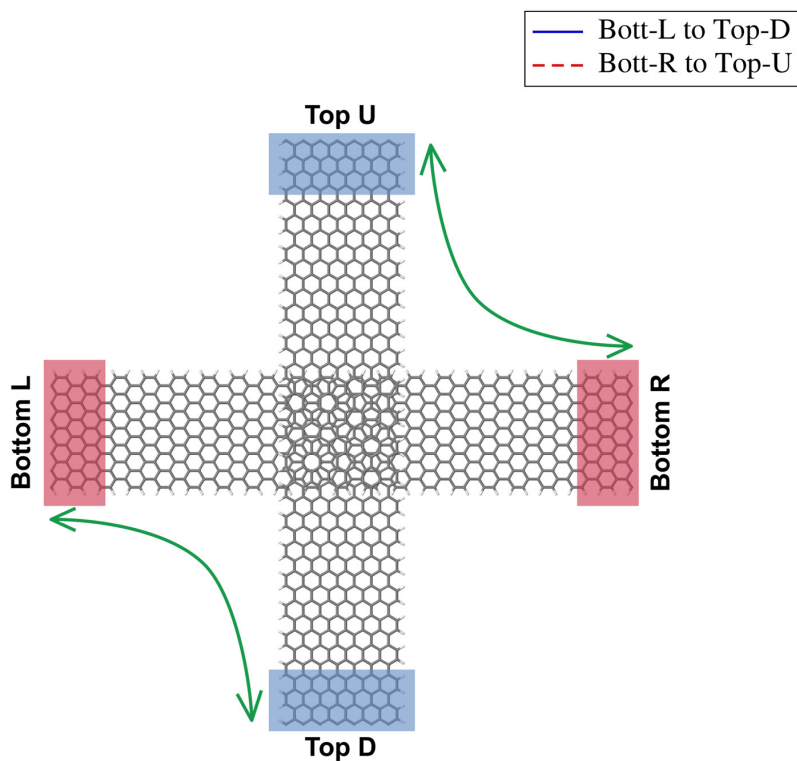


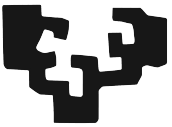
Direct transmission at $V = 0$



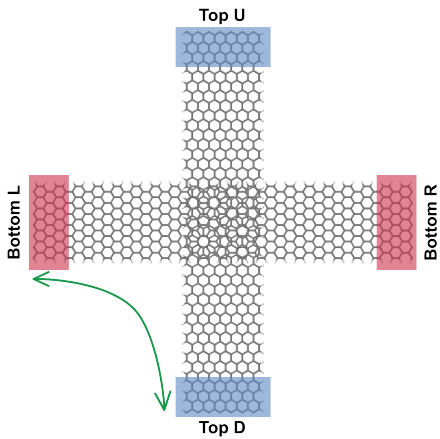


Inter-ribbon transmission at $V = 0$

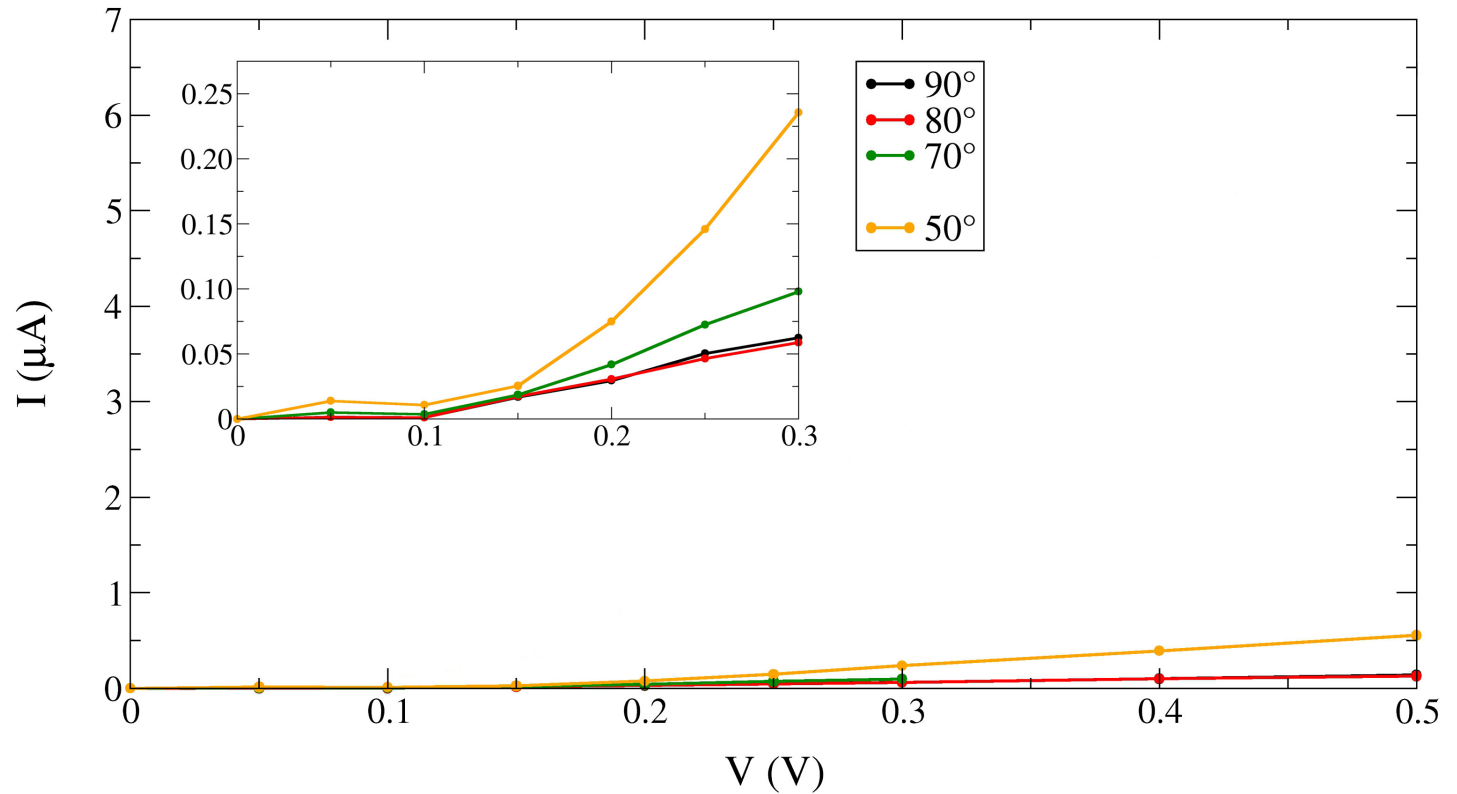




Inter-ribbon current

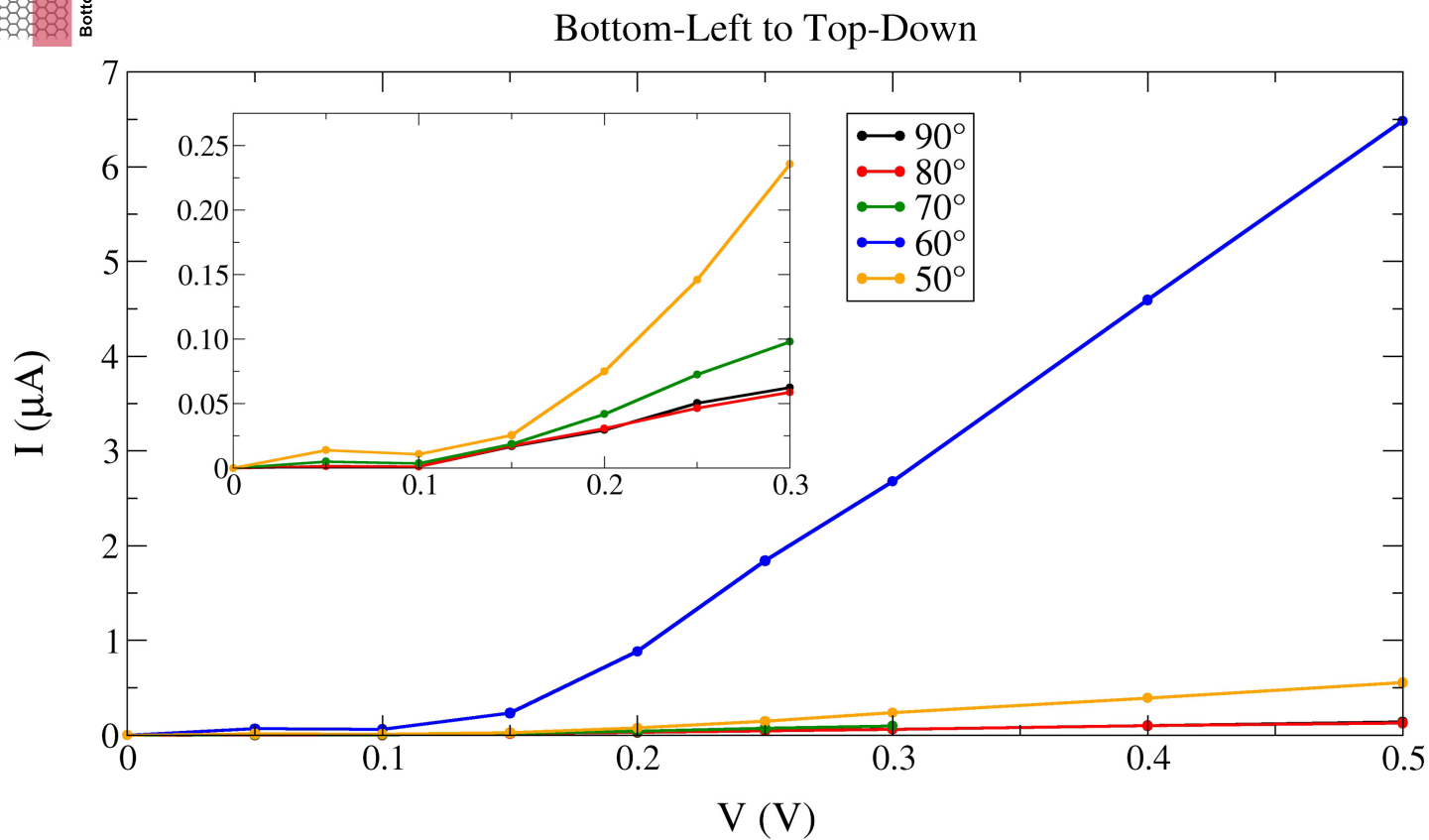
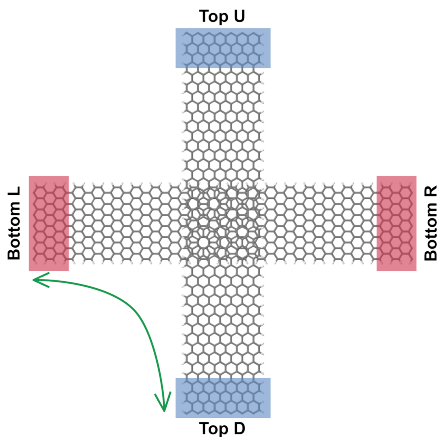


Bottom-Left to Top-Down



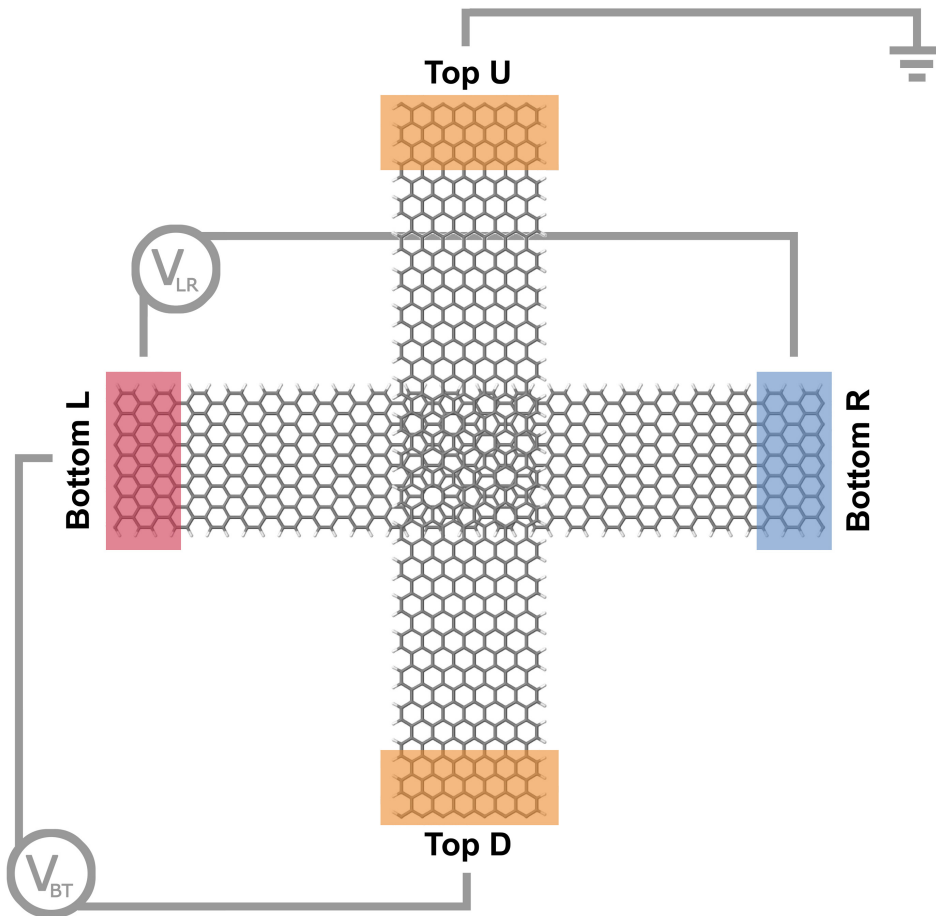


Inter-ribbon current



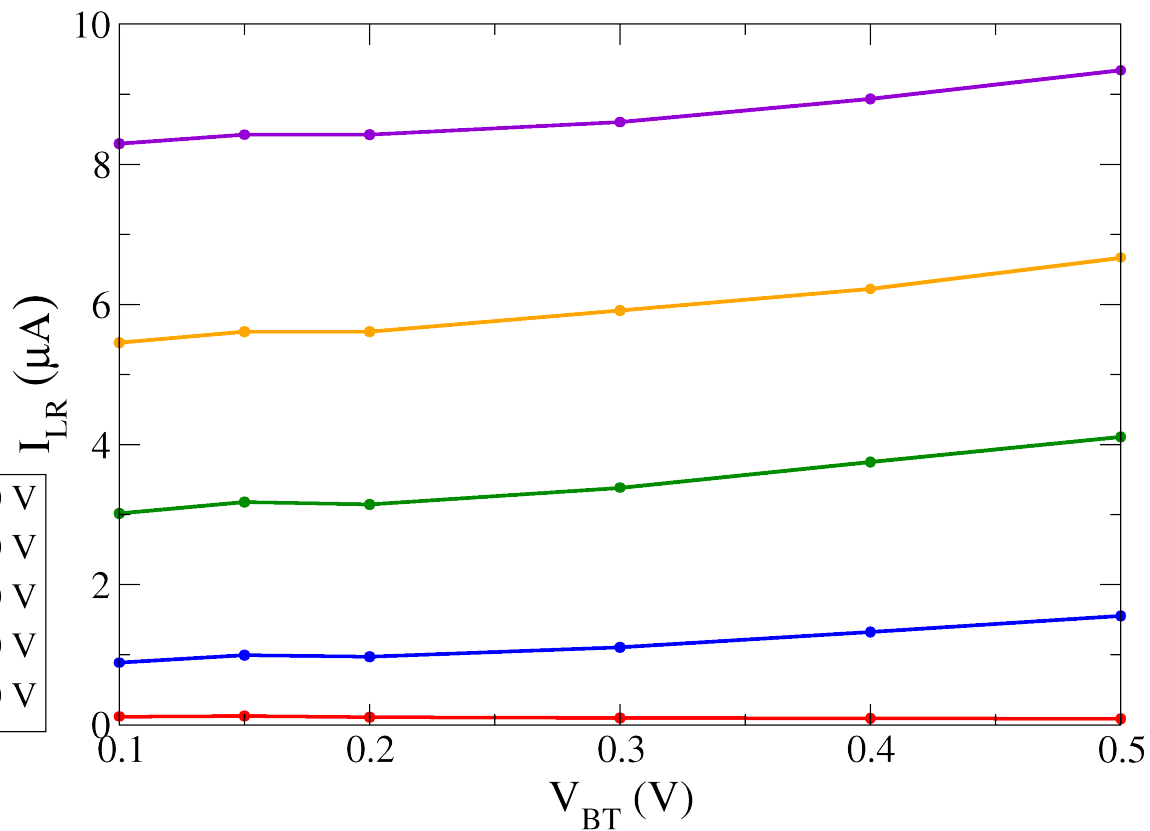
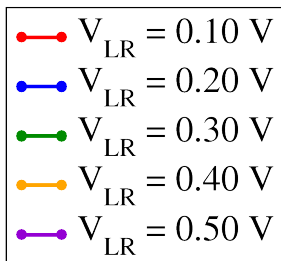
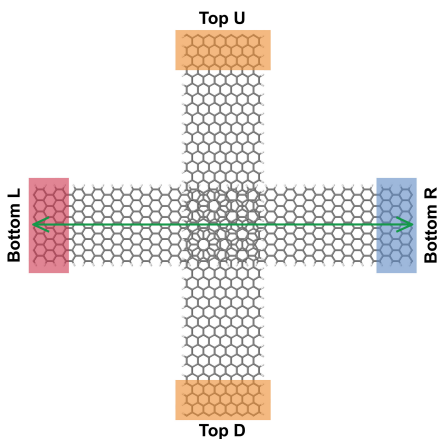


Intralayer bias



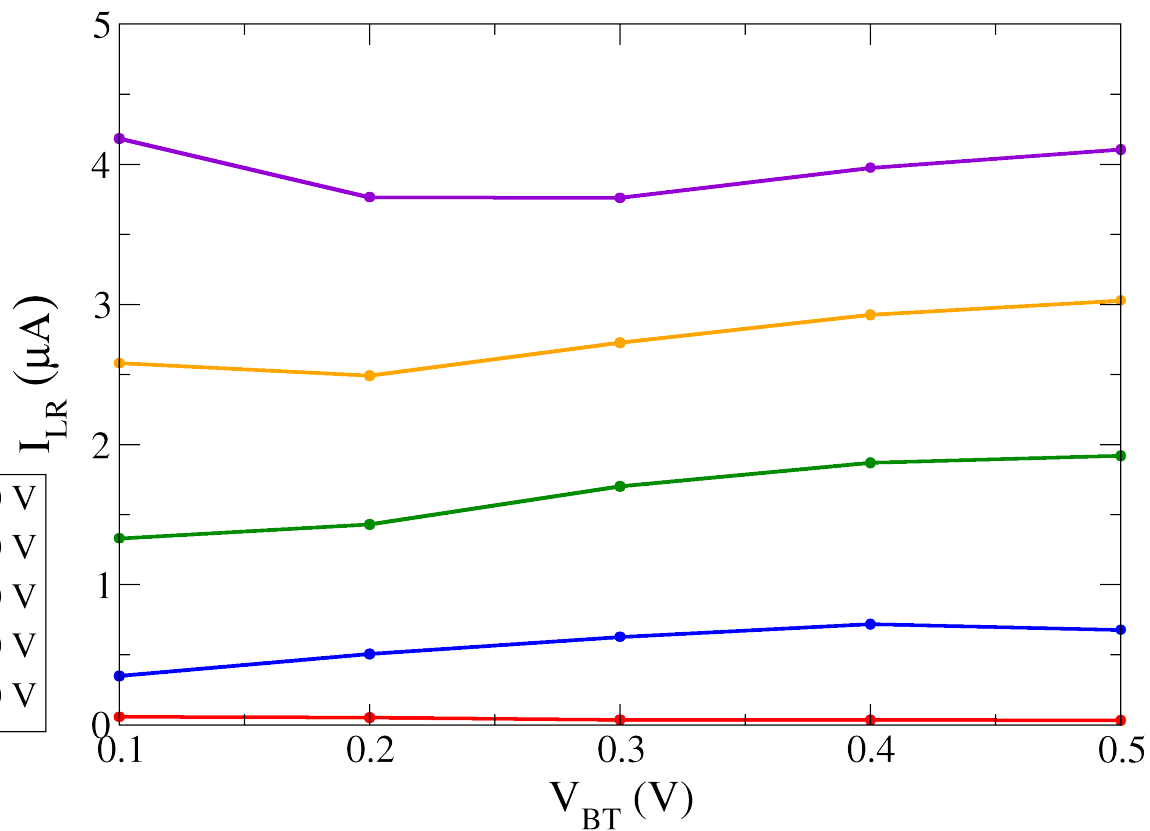
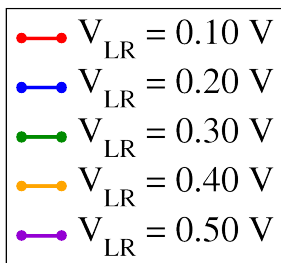
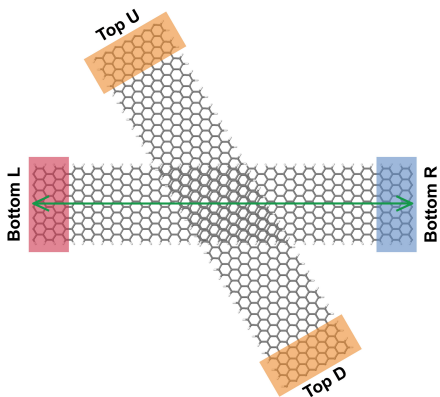


Intralayer bias





Intralayer bias





Conclusions

- TranSIESTA for **$N \geq 1$ arbitrarily distributed** electrodes at finite bias;
- Transmission **strongly depends on the stacking**;
- For a 60° rotation angle one finds a **higher inter-layer transmission**;
- In our calculations we observe a **small gating effect** due to the top ribbon.



Acknowledgements



GOBIERNO
DE ESPAÑA

MINISTERIO
DE ECONOMÍA
Y COMPETITIVIDAD



CSIC

CONSEJO SUPERIOR DE INVESTIGACIONES CIENTÍFICAS



Towards reality in modelling of molecular electronics

June 13-17, 2016 · Donostia-San Sebastián, Spain

Welcome

Donostia International Physics Center (DIPC) and FET-ICT project *Planar Atomic and Molecular Scale devices (PAMS)* are organizing the international workshop **Towards Reality in Modelling of Molecular Electronics (TRMME)** that will take place in San Sebastián, Spain, on **June 13-17, 2016**.

The aim of this workshop is to bring together experienced and young researchers, as well as students, working in the field of the theory of quantum transport and the development of computational tools for transport simulations in the nanoscale.



<http://trmme.dipc.org>